



Defect Chemistry of Solids

Malte Behrens

Fritz Haber Institute of the Max Planck Society

Department of Inorganic Chemistry

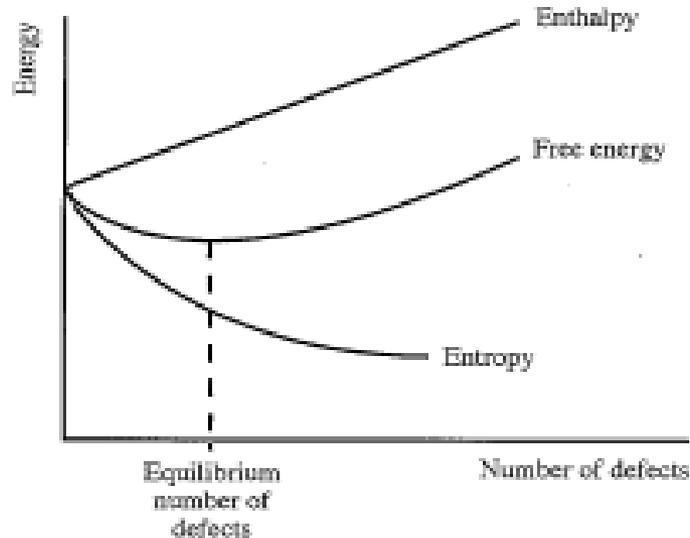
behrens@fhi-berlin.mpg.de

Outline

- **Fundamentals**
 - Ideal and real structure, intrinsic and extrinsic defects, thermodynamics of defects
- **Ionic solids**
 - Schottky and Frenkel defects, ionic conductivity, fast ion conductors
- **Transition metal oxides**
 - Non-stoichiometry and redox processes, cation and anion vacancies, electronic properties of defective oxides
- **Metals**
 - Dislocations, grain boundaries, stacking faults, properties of engineering materials
- **Defects in catalysis**
 - Characterization and role of defects in catalysts, examples

Ideal structure vs. real structure

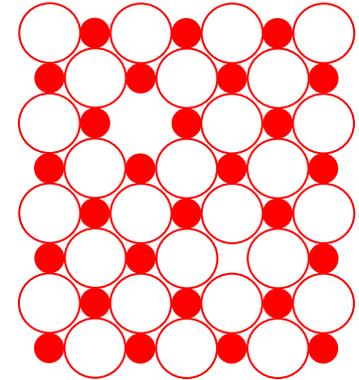
- Ideal structure of a solid: Every lattice point has exactly the same environment
- Deviations from ideal structure: Defects
- Intrinsic defects: $\Delta G = \Delta H - T\Delta S$



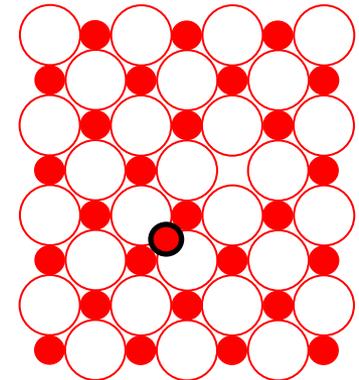
- Extrinsic defects: Non-stoichiometry, doping

Intrinsic point defects

- Schottky defect
(pairs of ions)



- Frenkel defect
(ion on interstitial site)



Thermodynamics of intrinsic defects

- n defects are distributed over N lattice sites:

$$W = \binom{N}{n} = \frac{N!}{n!(N-n)!} \quad \text{W possible arrangements}$$

- Boltzmann: $S = k \ln W$ with $\Delta G = \Delta H - T\Delta S$

$$\Delta G = n\Delta H_f - kT \ln \left(\frac{N!}{(N-n)!n!} \right) \quad \Delta H_f: \text{Enthalpy of formation for one defect}$$

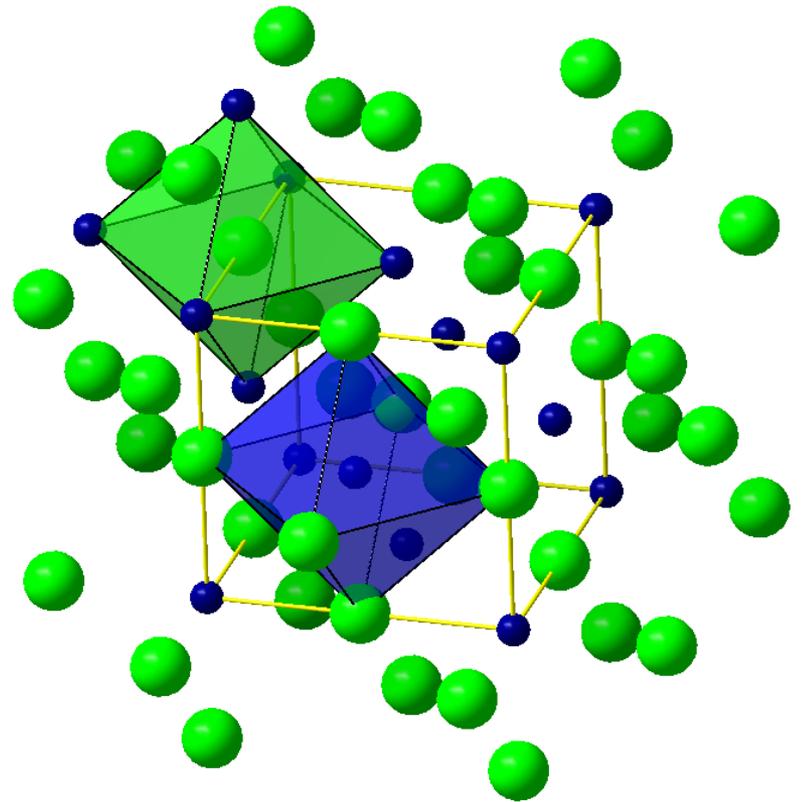
- Equilibrium, $T = \text{const.}$ $d(\Delta G) = \left(\frac{\partial \Delta G}{\partial n} \right)_T = 0$ with $\ln x! \approx x \ln x - x$

$$\ln \left(\frac{n}{N-n} \right) = - \frac{\Delta H_f}{kT}$$

- $n \ll N$: $\frac{n}{N} = e^{-\frac{\Delta H_f}{kT}}$ Schottky defects: $\frac{n}{N} = e^{-\frac{\Delta H_f}{2kT}}$

Ionic solids: Alkali halides

- Rocksalt structure
 - fcc packing of oxygen atoms
 - cations in every octahedral void
- NaCl, KCl: Schottky defects dominating
- AgCl: Frenkel defects dominating
 - 4d electrons tend to occupy free 3d orbitals of Cl⁻ (partial covalent bonding), favored at interstitial sites

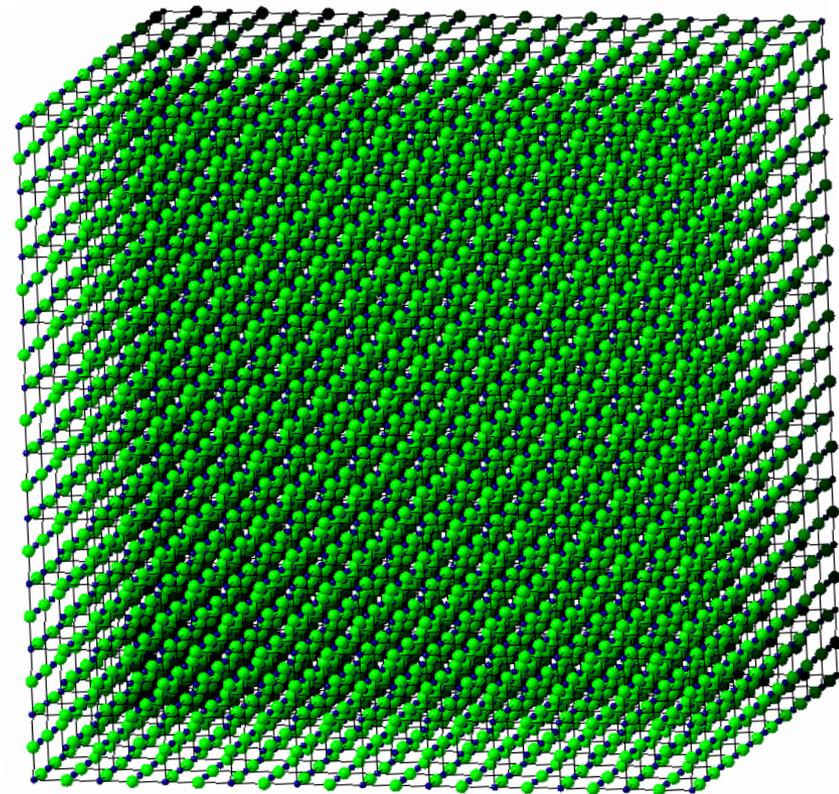


Defect structure of NaCl

- $\frac{n}{N} = e^{-\frac{\Delta H_f}{2RT}}$ $\Delta H_f(\text{NaCl}) \sim 200 \text{ kJ/mol}$

- 300 K:
 $< 10^{-13}$
 Schottky defects / 10.000 sites

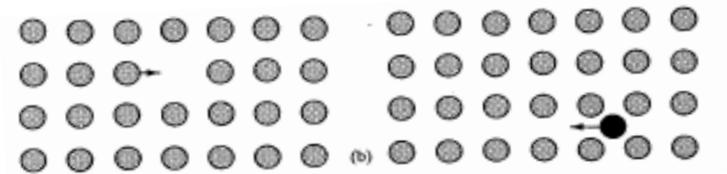
- 1000 K:
 < 0.1
 Schottky defects / 10.000 sites



10000 sites ~ 1000 unit cells

Ionic conductivity

- Point defects enhance the mobility of ions



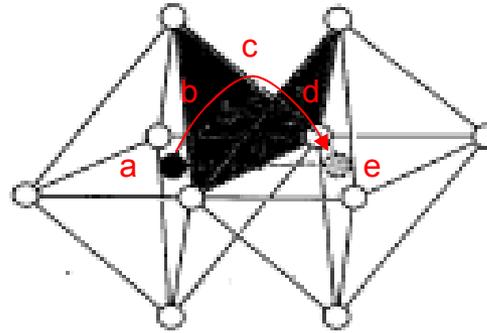
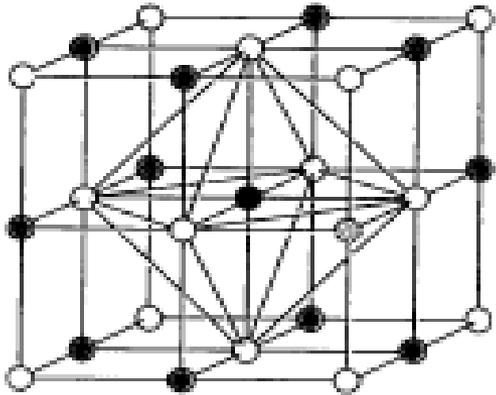
- Specific ionic conductivity

$$\sigma = nze\mu$$

n : number of ions
 ze : charge
 μ : mobility

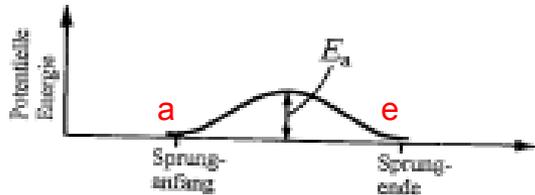
	<i>Material</i>	σ / Sm^{-1}
<i>Ionic conductors</i>	Ionic crystals	$<10^{-16} - 10^{-2}$
	Solid electrolytes	$10^{-1} - 10^3$
	Solutions of electrolytes	$10^{-1} - 10^3$
<i>Electronic conductors</i>	Metals	$10^3 - 10^7$
	Semiconductors	$10^{-3} - 10^4$
	Insulators	$<10^{-10}$

Ionic conductivity of NaCl



CN: 6 → 3 → 4 → 3 → 6

- X
- M
- ⊙ M-Vakanz



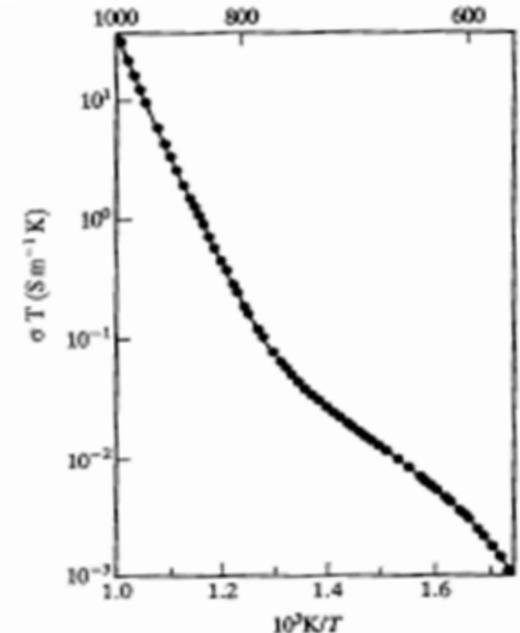
- T-dependence of atomic jumps

$$\mu = \mu_0 e^{-\frac{E_a}{kT}} \quad \text{Arrhenius}$$

- T-dependence ionic conductivity

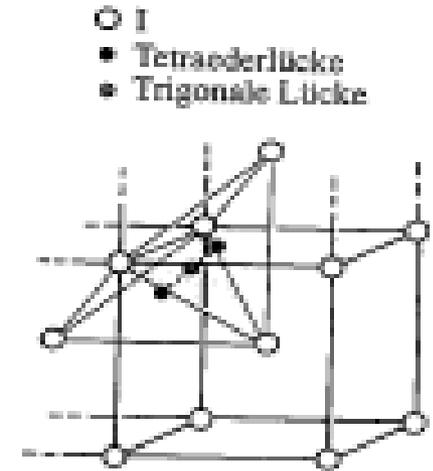
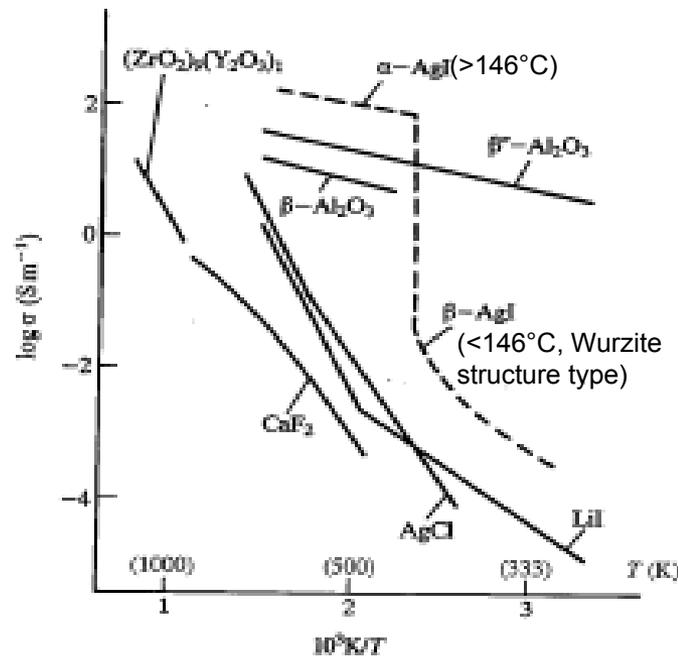
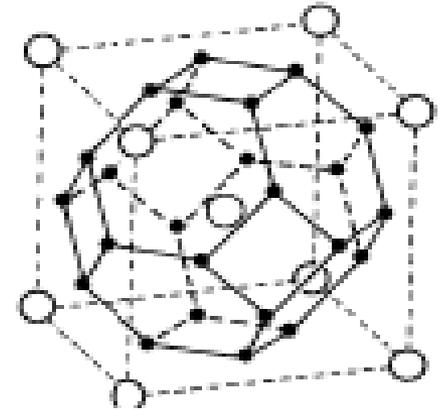
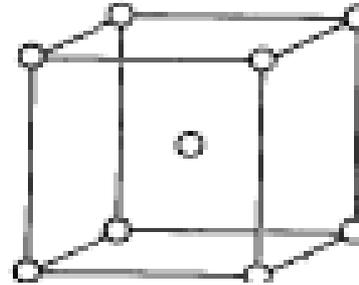
$$\sigma = nze\mu \quad \ln \sigma = \ln \sigma_0 - \frac{E_a}{T}$$

$$\sigma = \sigma_0 e^{-\frac{E_a}{T}} \quad \sigma = \sigma' e^{-\frac{E_a}{kT}} e^{-\frac{\Delta H_f}{2kT}}$$



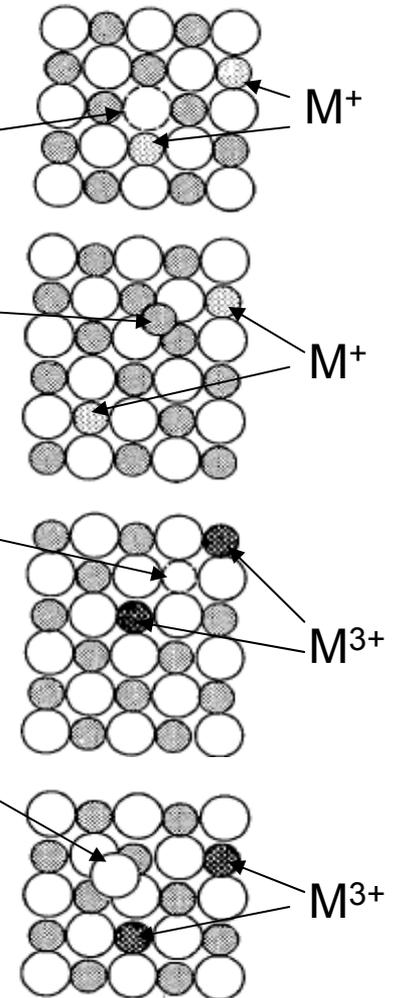
Fast ion conductors: α -AgI

- bcc arrangement of anions
- large and polarizable anion
- low charge of cations, low CN
- many vacant lattice sites
- conductivity comparable to solutions of strong electrolytes



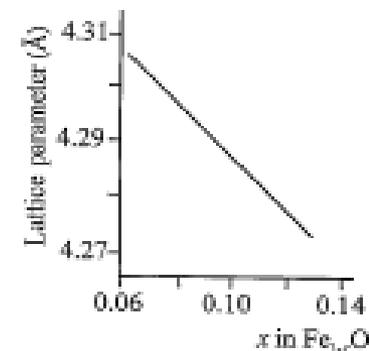
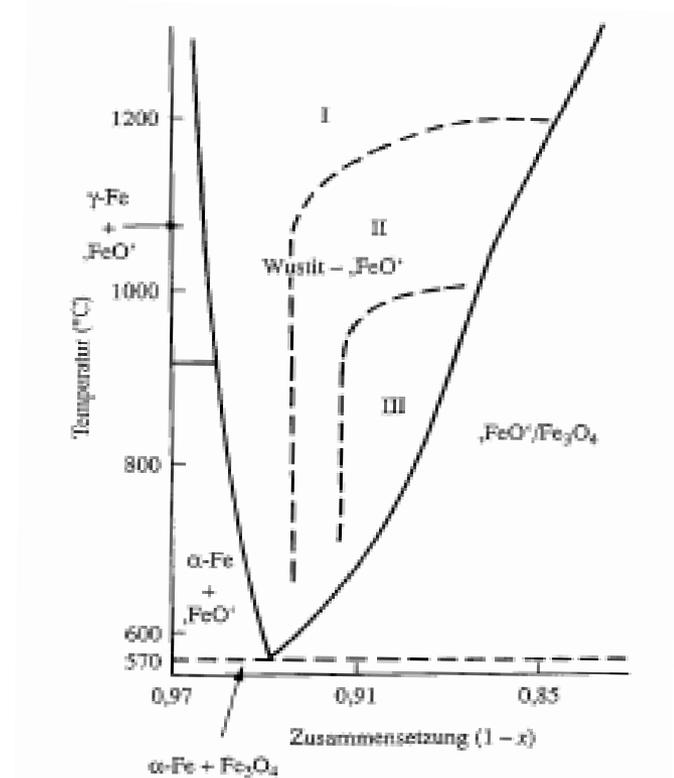
Defects in transition metal oxides

- 4 types of defective MO
 - Excess metal:
 - Anion vacancies MO_{1-x}
 - Interstitial cations M_{1+x}O
 - Excess oxygen:
 - Cation vacancies M_{1-x}O
 - Interstitial anions MO_{1+x}
- Non-stoichiometry in transition metal oxides is often compensated by change of oxidation state (partial oxidation or reduction of the metal)



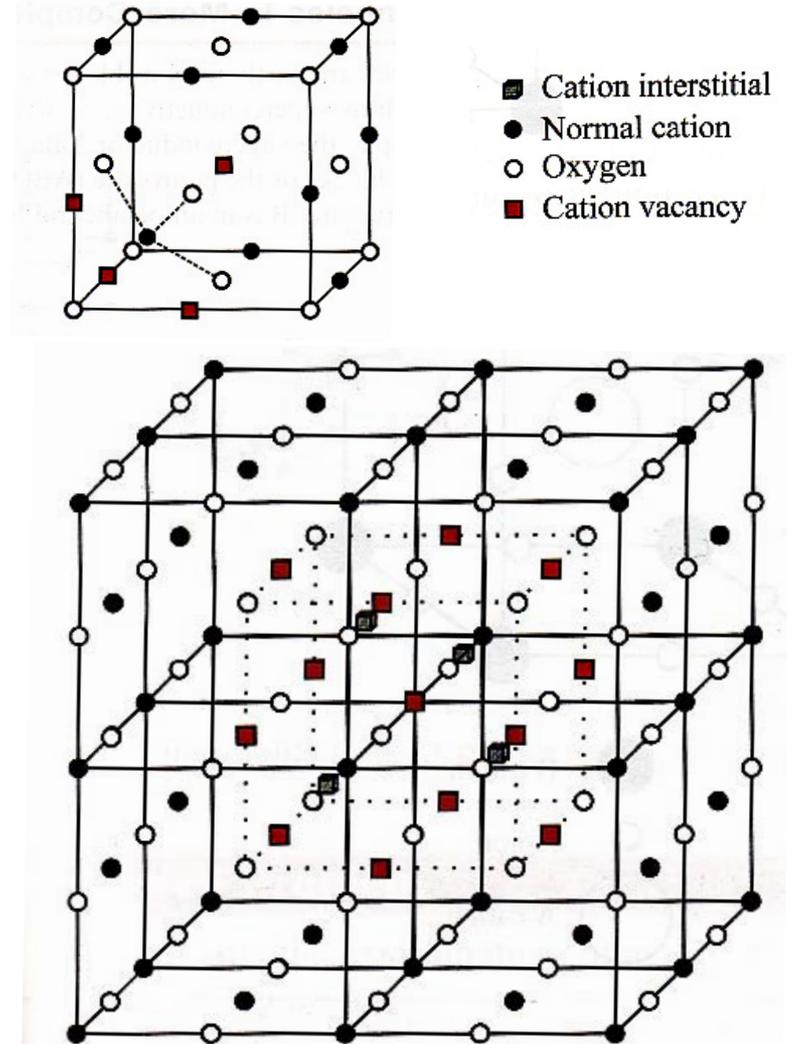
Rocksalt-type oxides: Wuestite

- “FeO” is always Fe-deficient
- Presence of extra O^{2-} on interstitial sites can be excluded from density measurements \rightarrow Fe vacancies $Fe_{1-x}O$
- Gradual change of lattice parameter with x in $Fe_{1-x}O$
- For each Fe vacancy, two Fe(II) have to be oxidized to Fe(III)



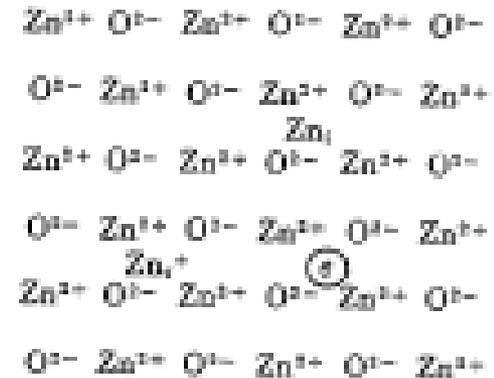
Clustering of defects in Fe_{1-x}O

- Diffraction studies have shown that some Fe atoms are located on tetrahedral sites
- Mößbauer data reveals that Fe^{tet} is Fe(III)
- As the distance between octahedral and tetrahedral sites is short, vacancies cluster around occupied tetrahedral sites
- Koch-Cohen cluster: 4 interstitial Fe^{tet} and 13 vacancies
- “ Fe_3O_4 ($\text{FeO}\cdot\text{Fe}_2\text{O}_3$) –like domains in Fe_{1-x}O ”



Non-stoichiometry of ZnO

- Wurzite (ZnS) structure type
 - hexagonally packed oxygen anions
 - half of the tetrahedral voids filled with Zn^{2+}
- Upon heating some zinc is partially reduced and migrates to interstitial sites
 - $Zn_{1.00007}O$ at 800 °C:
“ZnO” is yellow
- Interstitial Zn atoms act as electron donators
 - $Zn_i^{(2-x)+} \rightarrow Zn_i^{2+} + x e^-$

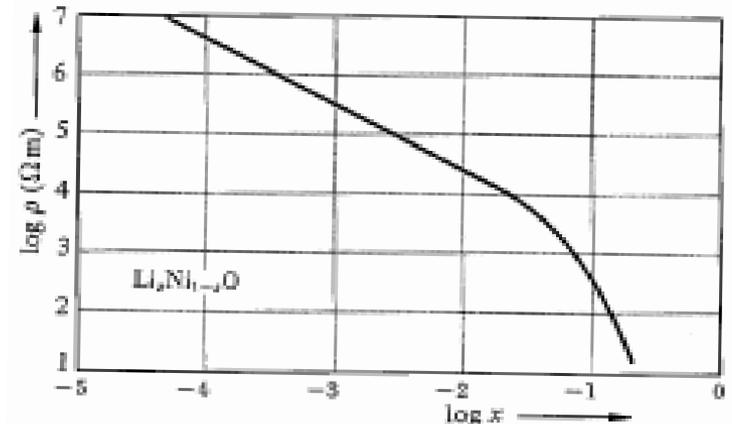
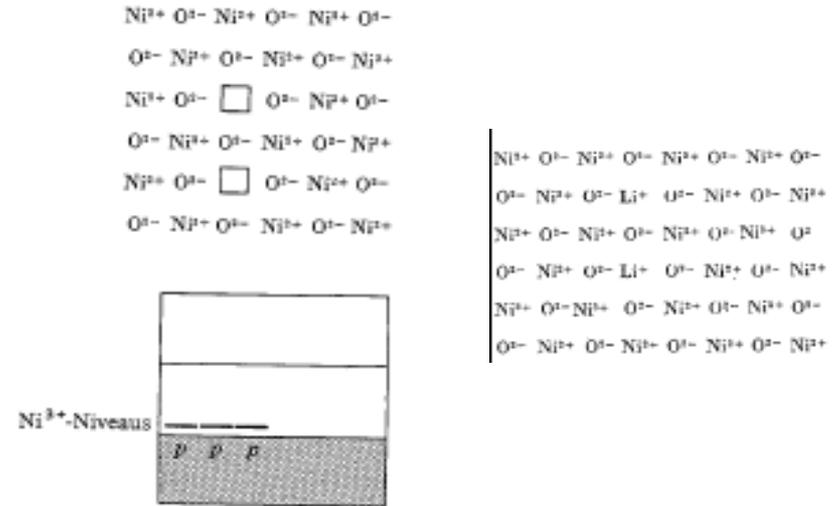


Non-stoichiometry of NiO

- Stoichiometric NiO is an insulator and green (bandgap 3.8 eV)
- Non-stoichiometric $\text{Ni}_{0.98}\text{O}$ (NaCl structure type) is a semiconductor and black
- Formation of Ni vacancies by oxidation :

$$2 \text{Ni}^{2+} + \frac{1}{2} \text{O}_2 \rightarrow \text{O}^{2-} + \square + 2 \text{Ni}^{3+}$$
- Ni^{3+} in the lattice is an acceptor for electrons
- Li doping ($0 \leq x \leq 0.1$):

$$\text{Li}_x\text{Ni}_{1-x}\text{O}$$
- As conductive as typical metals



Measuring the electronic properties of non-stoichiometric transition metal oxides

- A: extra electrons in the conduction band as charge carriers



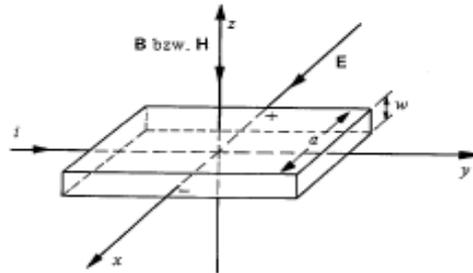
Defects donor levels

- B: extra holes in the valence band as charge carriers



Defects acceptor levels

- Hall effect



$$E_y = -\frac{j_x B_z}{ne}$$

n ; $-e$: electron concentration and charge

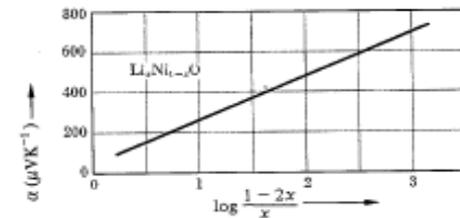
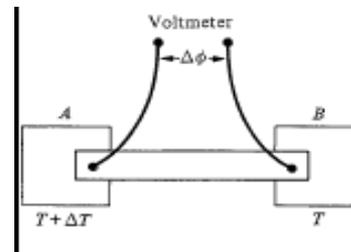
$$R_H = \frac{E_y}{j_x B_z} = -\frac{1}{ne}$$

for electrons

$$R_H = +\frac{1}{pe} \quad \text{for holes}$$

- Seebeck effect

$$\Delta\Phi = \Phi_A - \Phi_B = -\alpha\Delta T$$

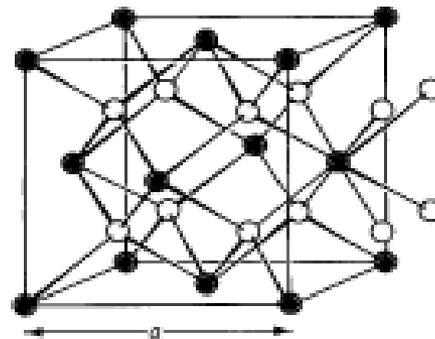


α (Seebeck coefficient) positive if holes are the major charge carrier, negative for electrons

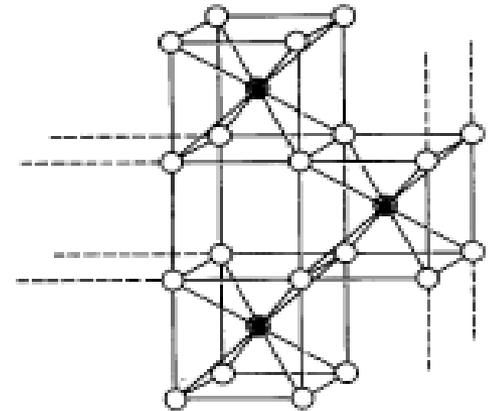
Flourite-type oxides

- CaF_2 structure type: large and highly charged cations, small anions (PbF_2 , UO_2 , ZrO_2)

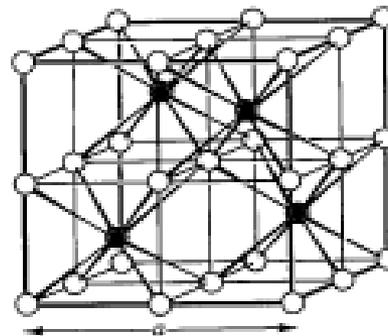
- fcc packing of cations, anions in tetrahedral voids
- large octahedral voids are vacant, anion mobility via interstitial sites



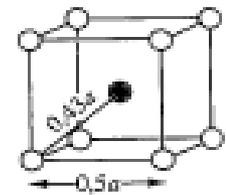
(a)



(b)



● Kation ○ Anion



(d)

Crystal chemistry of ZrO₂

X.-J. Jin / Current Opinion in Solid State and Materials Science 9 (2005) 313-318

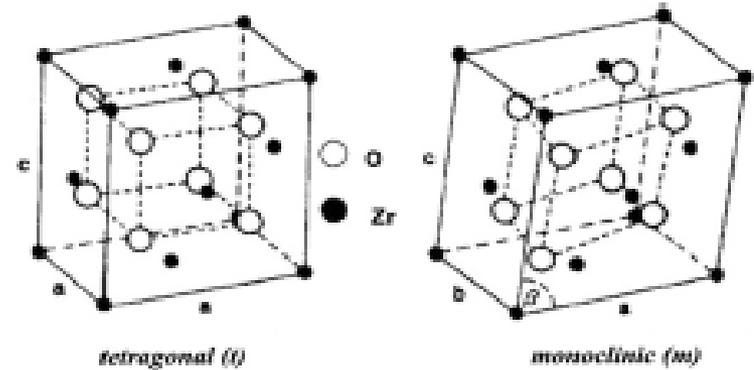
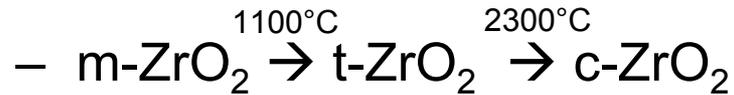
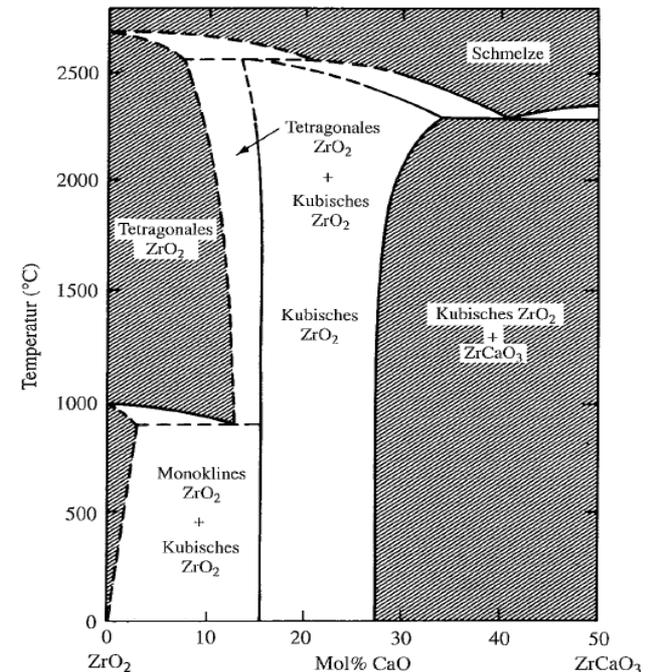


Fig. 1. Crystal structures of tetragonal (t) and monoclinic (m) phases [7].

- Martensitic phase transformations of ZrO₂



- Cubic ZrO₂ (CaF₂ structure type) is stable above 2300 °C or can be stabilized by cation substitution



Applications of stabilized zirconia

- Solid electrolyte, e.g. in fuel cells
- Oxygen sensor

$$E = \frac{2.3RT}{4F} \log \left(\frac{p'}{p_{ref}} \right) \quad \text{Nernst}$$

- Application: 3-way catalyst
 - Simultaneous oxidation of C_nH_m and CO and reduction of NO_x requires optimal air/exhaust gas ratio ($\lambda = 1$)
 - λ -sensor: Yttrium stabilized zirconia (YSZ), ca. 3 mol-% Y_2O_3

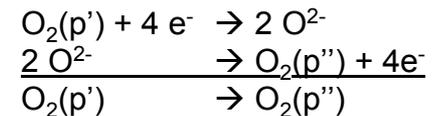
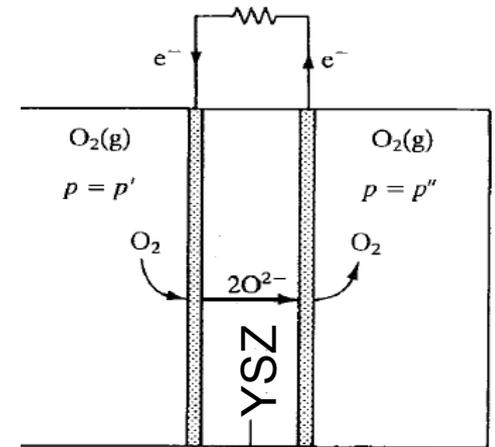
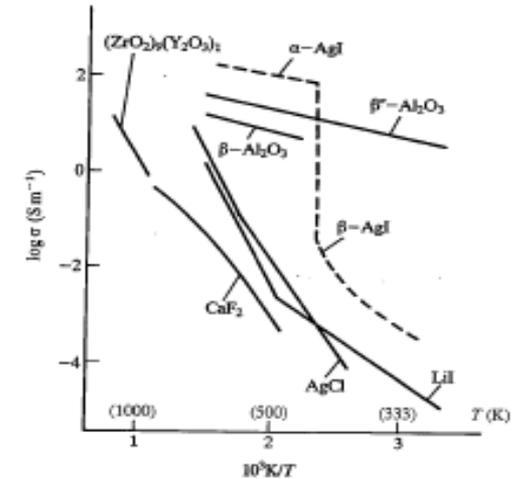
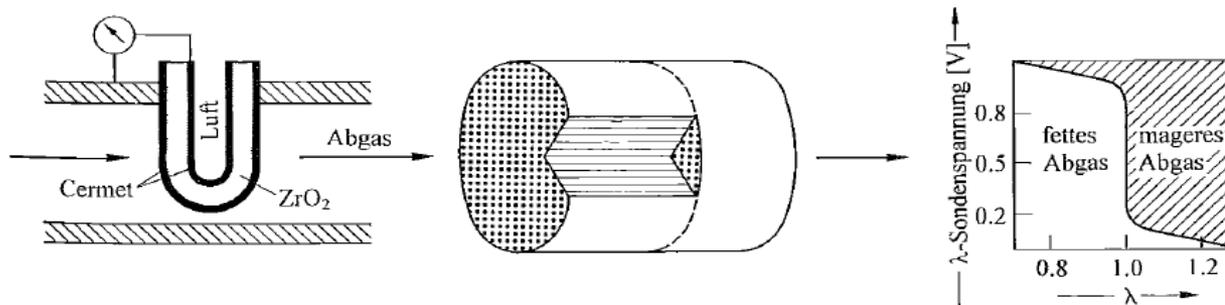
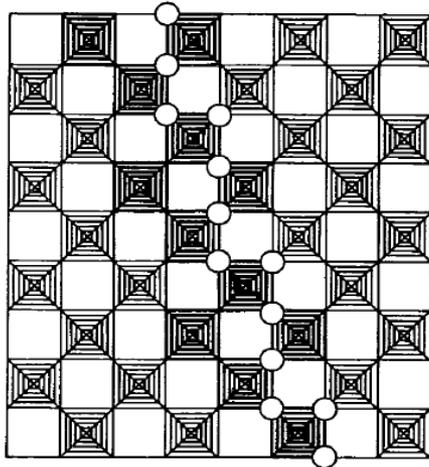
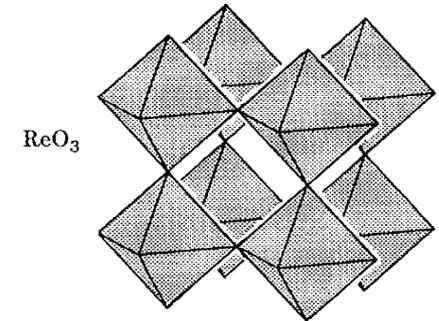
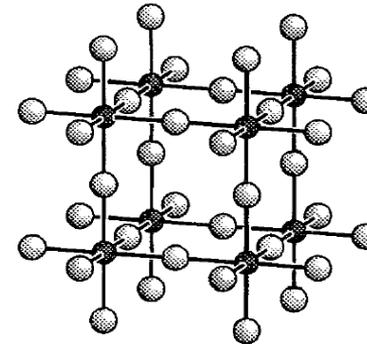


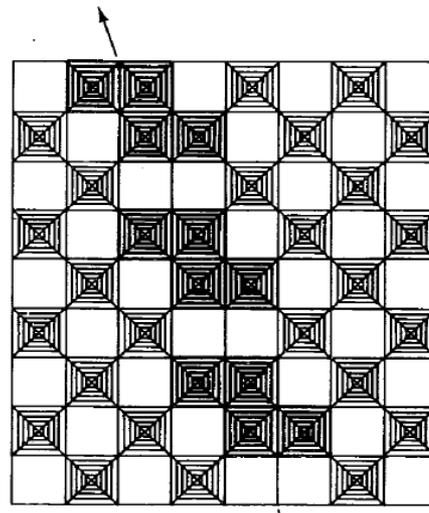
Fig. 156 λ -Sonde, Dreiweg-Katalysator und λ -Sondenspannung in Abhängigkeit von λ .

Extended defects

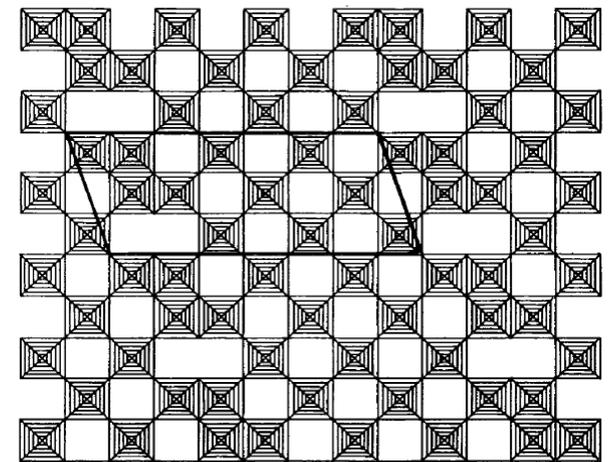
- Crystallographic shear
 - Elimination of vacancies by crystallographic shear: $MO_{3-x} = M_n O_{3n-1}$, $M = Mo, W, n \geq 4$



(a)
○ : Leerstelle
 WO_3

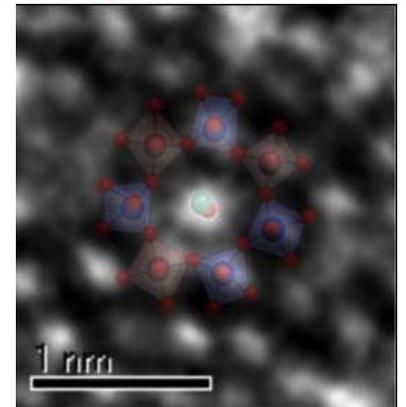
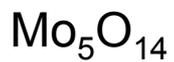
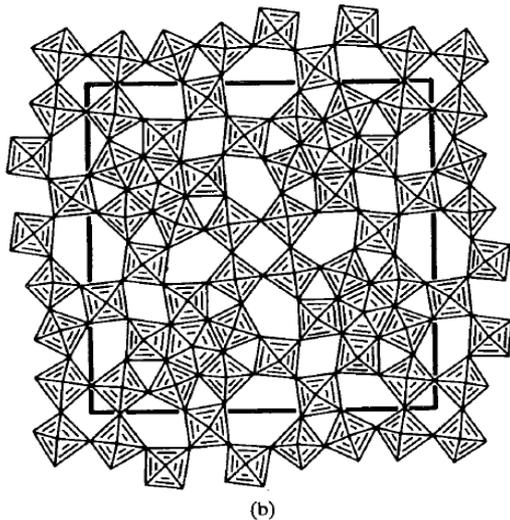
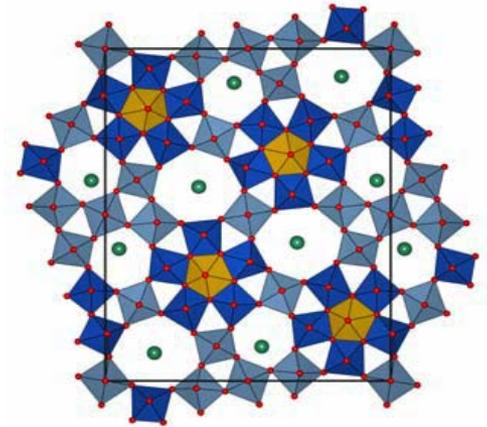
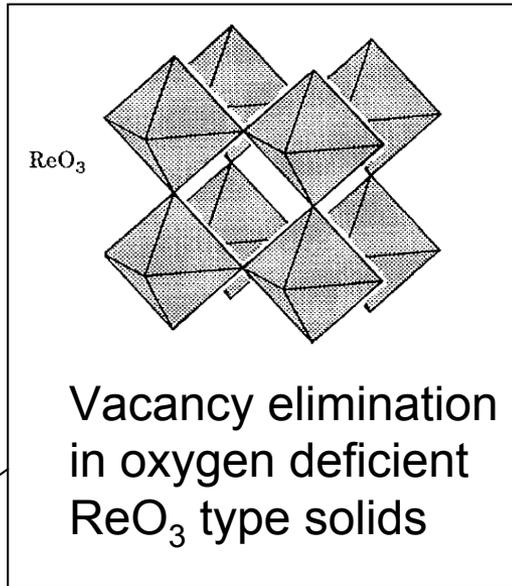
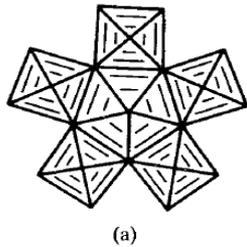


(b)
 WO_{3-x}



$W_{11}O_{32}$

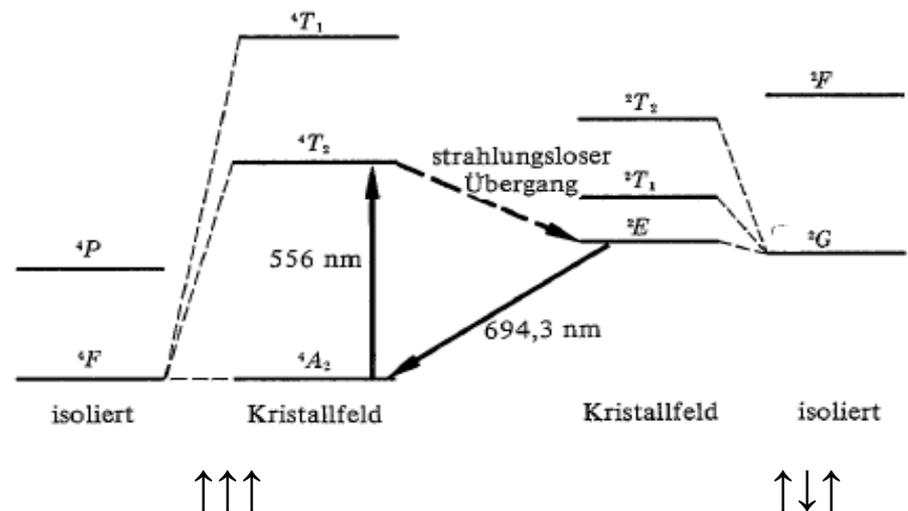
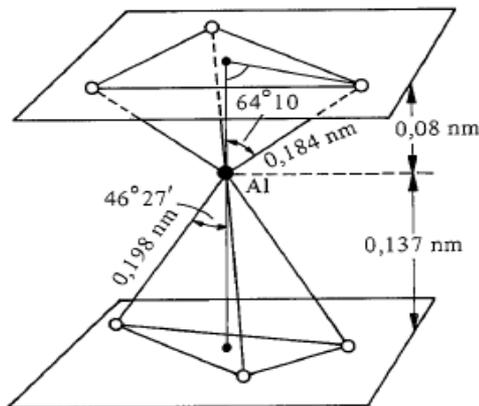
ReO₃ type oxides



MoVTeNb catalyst (M1)

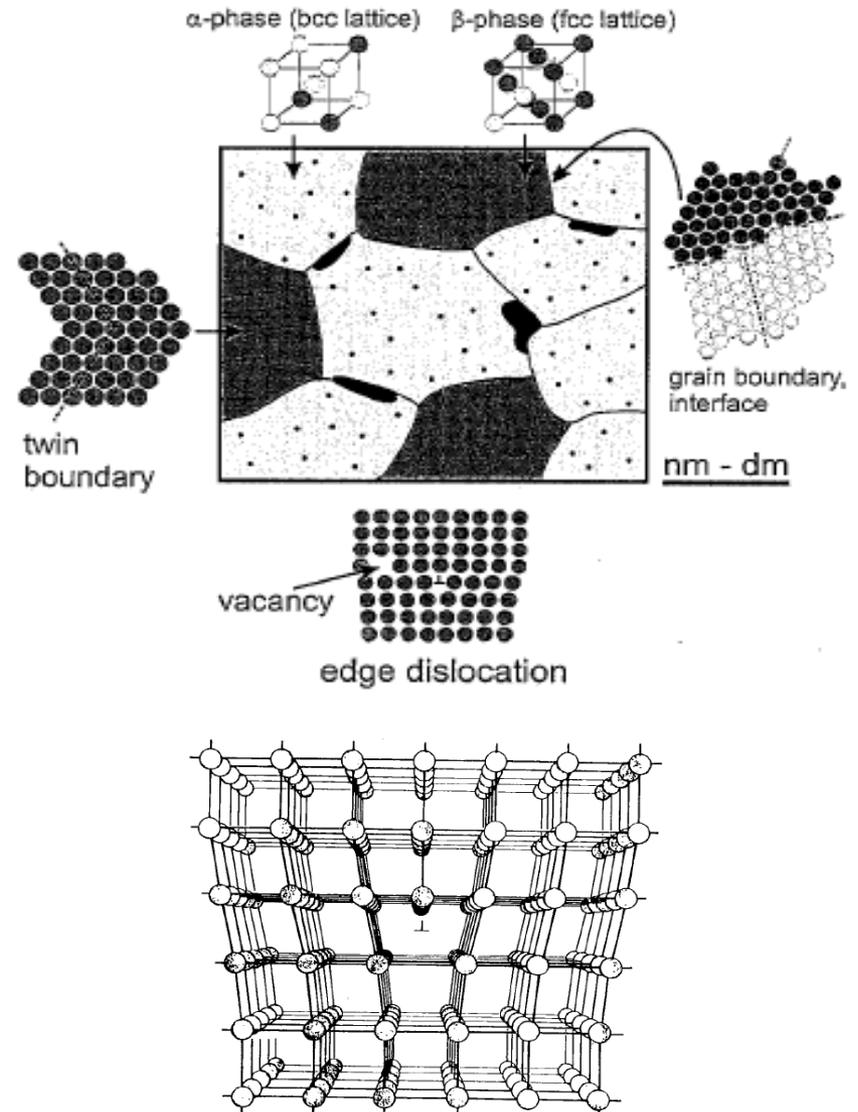
Solid solutions: Oxides

- Ruby: 0.04–0.5 % Cr^{3+} in $\alpha\text{-Al}_2\text{O}_3$
- Structure of corundum
 - hexagonal packing of oxygen, $\frac{2}{3}$ of octahedral voids occupied by Al^{3+}
- Isomorphous substitution Al^{3+} by Cr^{3+}
- Application: Ruby laser



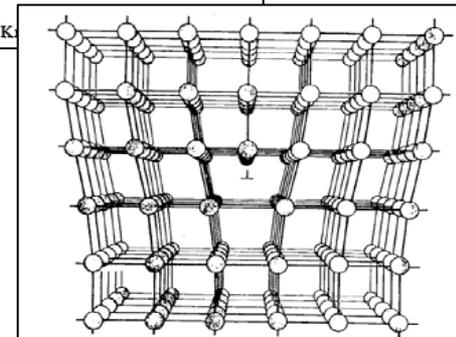
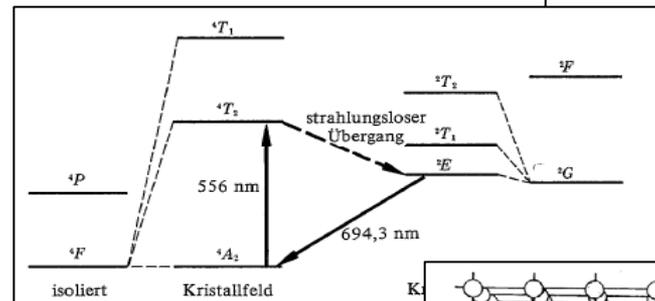
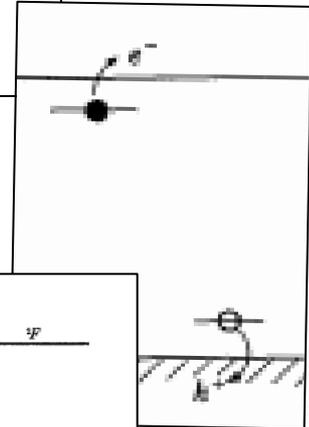
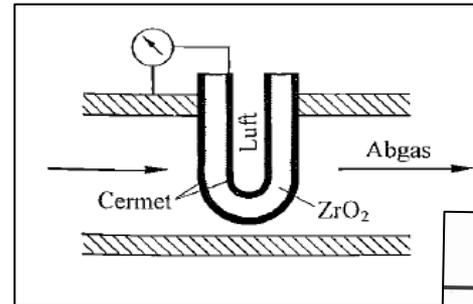
Defects in metals

- Microstructure of engineering materials
 - point defects
 - grain boundaries
 - interfaces
 - twin boundaries
 - dislocations

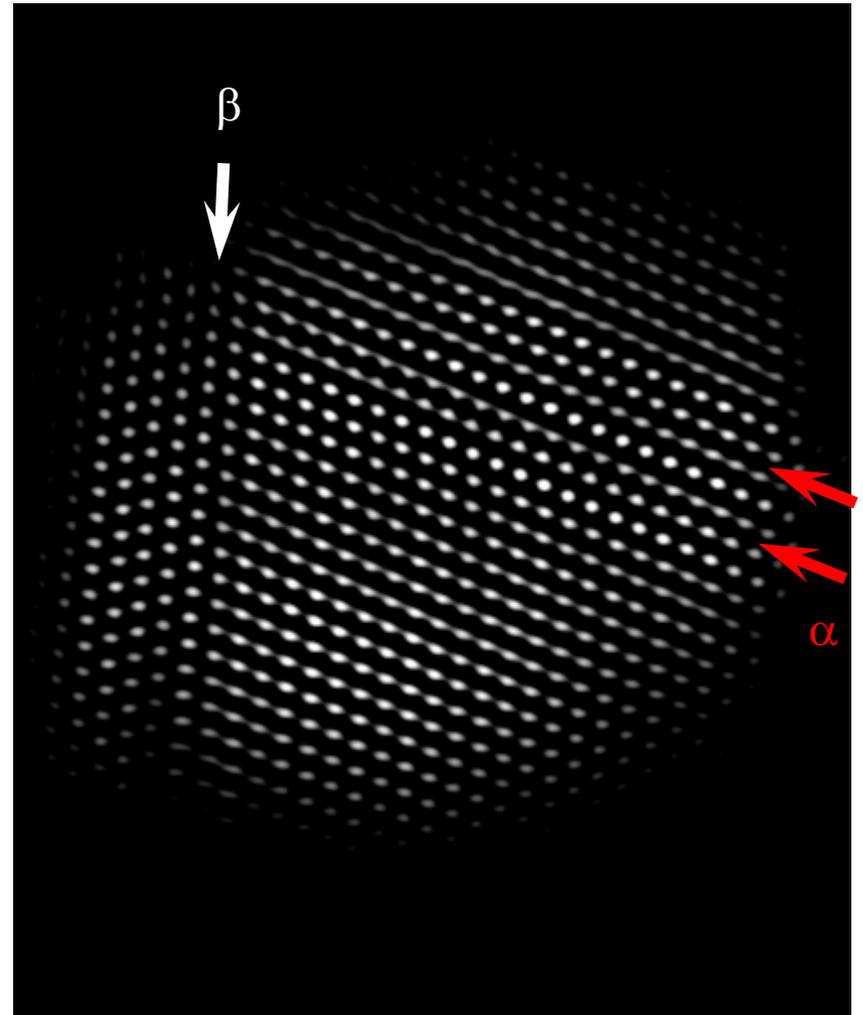
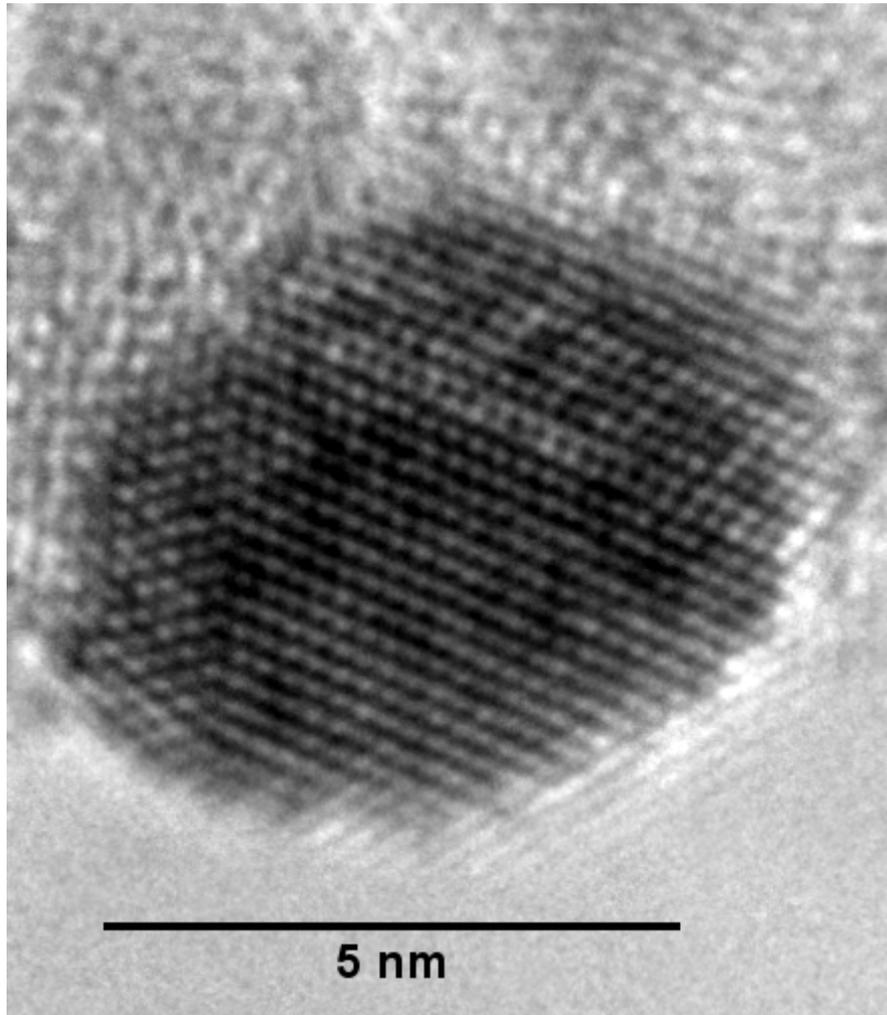


Properties governed by defects

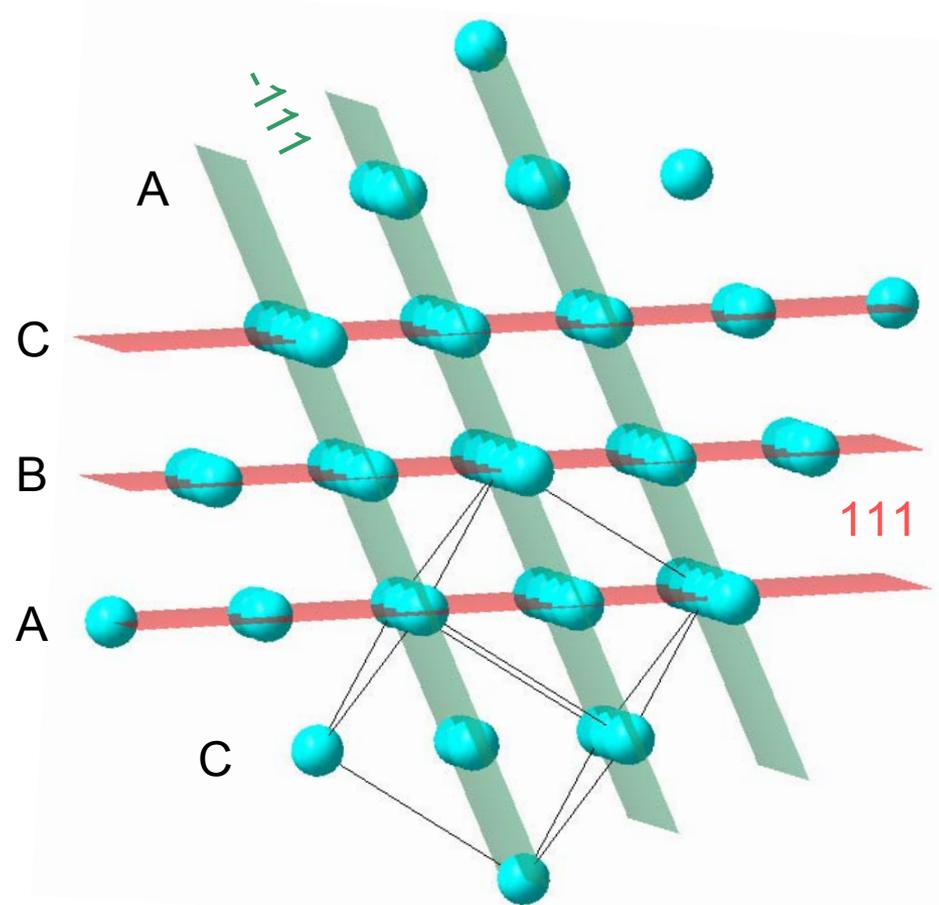
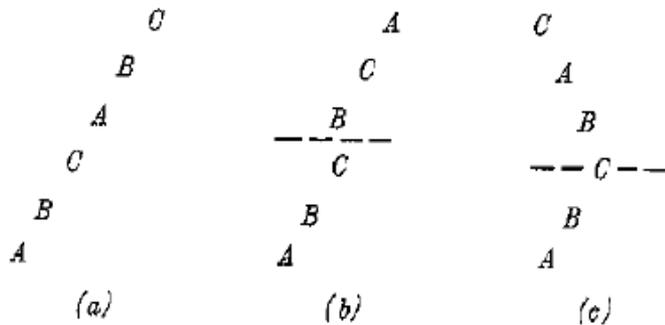
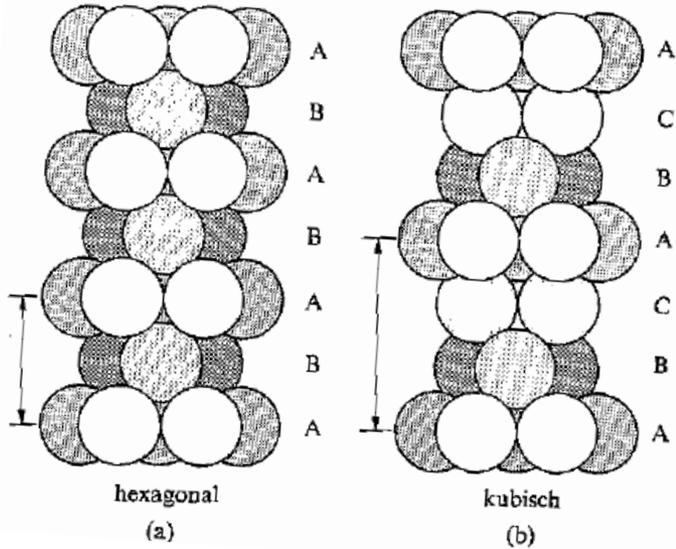
- Ionic conductivity
 - fast ion conductors
 - solid electrolytes
 - gas sensors
- Electronic properties of semiconductors
 - electronics
- Optical properties
 - luminescence
 - laser
- Mechanical properties
 - hardness of metals
- ...
- ... and catalysis?



Microscopy: Planar defects in Cu catalysts



Diffraction: Planar defects in Cu

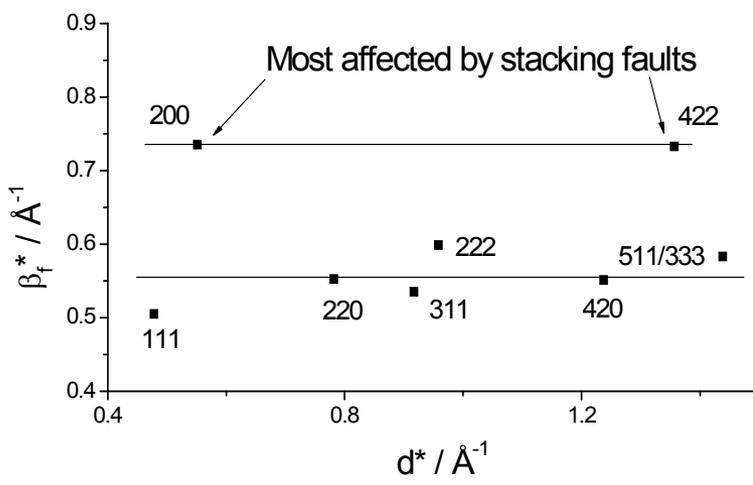
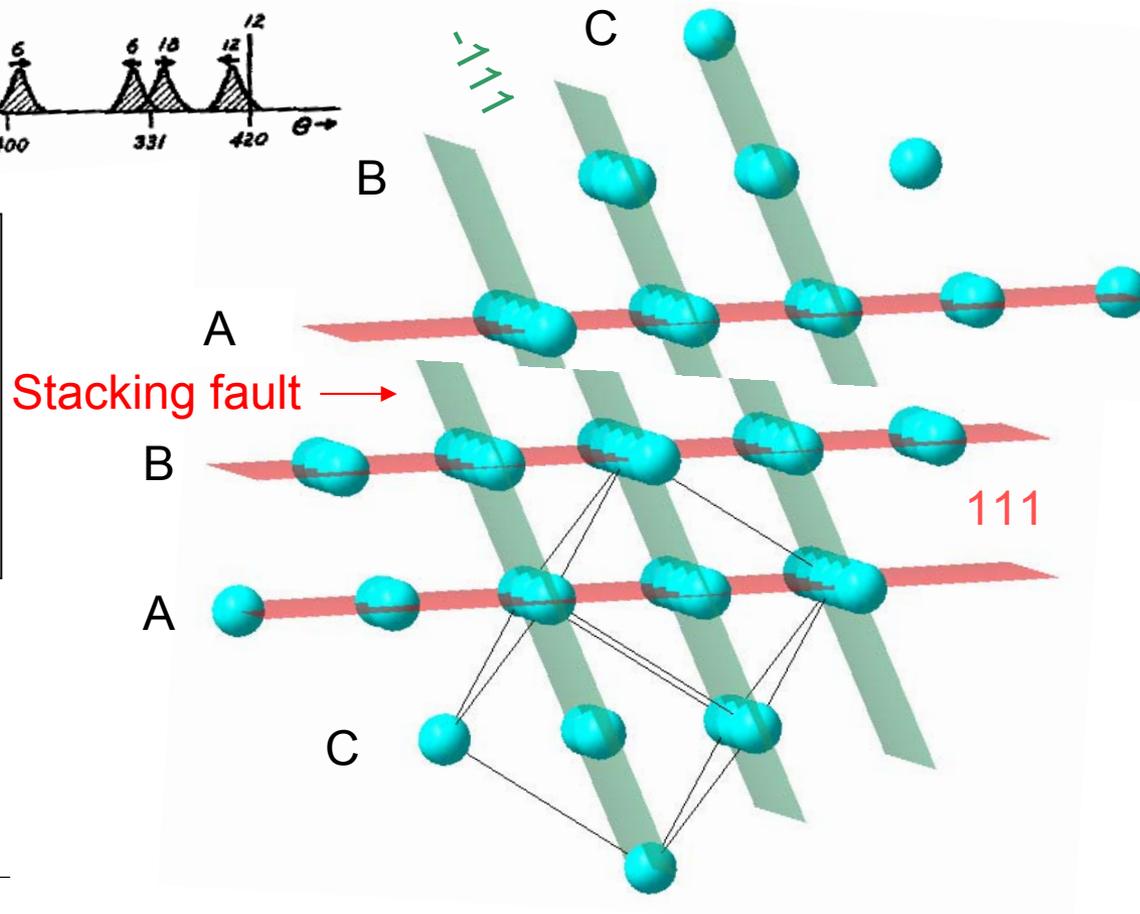


Stacking faults in fcc materials



111, -1-1-1
not affected
($h+k+l=3N$)

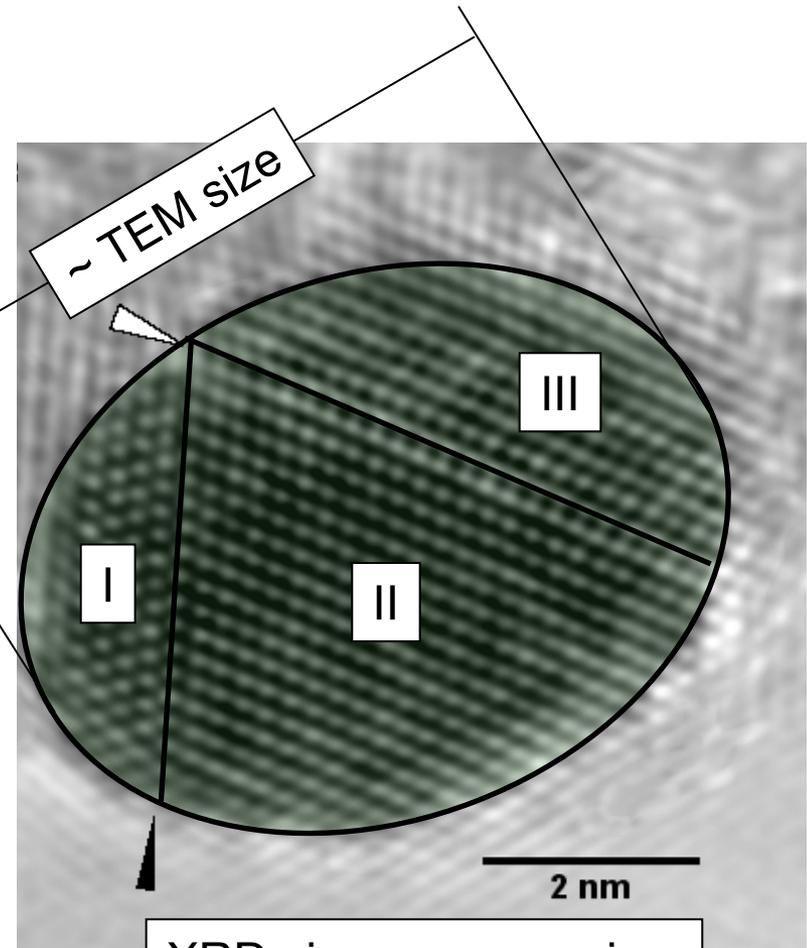
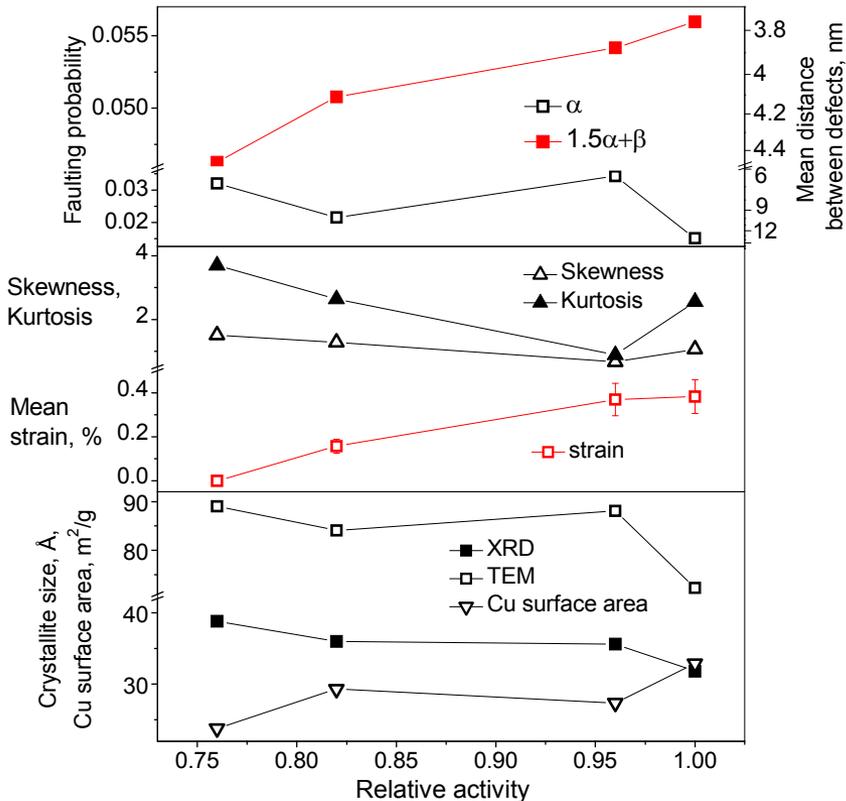
-111, 1-11,
11-1, -1-11,
1-1-1, -11-1
broadened
and shifted
($h+k+l=3N\pm 1$)



Williamson-Hall plot from neutron data

Combined XRD and TEM approach

$$D = \frac{a \cdot D_{111}}{a - (1.5\alpha + \beta)D_{111} \sqrt{3}/2}$$



XRD size: average size of volumes I, II & III

Literature and references

- L. Smart, E. Moore, "Einführung in die Festkörperchemie" (German), Vieweg, Braunschweig, 1997
- W. J. Moore, "Der feste Zustand" (German), Vieweg, Braunschweig, 1977
- A. F. Hollemann, N. Wieberg, "Lehrbuch der Anorganischen Chemie" (German), de Gruyter, Berlin, 1995
- P. A. Cox, "The Electronic Structure and Chemistry of Solids" Oxford University Press, Oxford, 1987
- U. Müller, "Anorganische Strukturchemie" (German), Teubner, Stuttgart, 1991
- S.E. Dann "Reaction and Characterization of Solids" RSC, Cambridge 2000.
- W. Reimers, A.R. Pyzalla, A. Schreyer, H. Clemens (ed), "Neutrons and Synchrotron Radiation in Engineering Materials Science", Wiley, Weinheim, 2008
- I. Kasatkin, P. Kurr, B. Kniep, A. Trunschke, R. Schlögl, Angew. Chem. 119, 2007, 7465
- M.S. Paterson, J. Appl. Phys. 23, 1952, 805
- X.-J. Jin, Current Opin. Solid State Mater. Sci. 9, 2005, 313